



## Sputtering Target for Semiconductor Industry Research Report 2026

Industry	Published	Pages	Format
Electronics & Semiconductor	2025-12-30	132	PDF

  

Single User	Multi User	Enterprise
USD 2,950	USD 4,430	USD 5,900

### Description

The sputtering target material is the core of semiconductor wafer manufacturing, and the chip has very high requirements for sputtering target material, which requires high purity of target material, generally over 99.999%.

As for global Sputtering Target for Semiconductor market, there are several key players, like Materion (Heraeus), JX Nippon Mining & Metals Corporation, Praxair, Plansee SE, Hitachi Metals, Honeywell, TOSOH, Sumitomo Chemical, ULVAC, Ningbo Jiangfeng, Luvata, GRIKIN Advanced Material, Luoyang Sifon Electronic Materials, FURAYA Metals, Advantec, Fujian Acetron New Materials Co., Ltd, Umicore Thin Film Products, Angstrom Sciences, Changzhou Sujing Electronic Material, etc.

Asia-Pacific is the largest consumption region of Sputtering Target for Semiconductor, with a consumption market share nearly 52%. The second place is North America; following Asia-Pacific with the consumption market share over 23%.

### Report Scope

This report quantifies the global Sputtering Target for Semiconductor market in revenue (US\$ million) and, where applicable, sales volume (Tons), using 2025 as the base year and providing annual historical and forecast data for 2021–2032.

It standardizes definitions of types and applications, harmonizes vendor attribution, and presents comparable time series by company, type, application, and region/country, including indicative price bands (US\$/Tons) and concentration ratios (CR5/CR10).

The outputs are intended to support strategy development, budgeting, and performance benchmarking for manufacturers, new entrants, channel partners, and investors; the report also reviews technology shifts and notable product introductions relevant to Sputtering Target for Semiconductor.

### Key Companies & Market Share Insights

This section profiles leading manufacturers, combining 2021–2025 results with a 2026–2032 outlook. It reports revenue, market share, price bands, product and application mix, regional and channel mix, and key developments (M&A, capacity additions, certifications). It also provides global revenue, average price, and—where applicable—sales volume by manufacturer, and calculates CR5/CR10 and rank changes to support comparative benchmarking.

Sputtering Target for Semiconductor Market by Company

Materion (Heraeus)

JX Nippon Mining & Metals Corporation

Praxair

Plansee SE  
Hitachi Metals  
Honeywell  
TOSOH  
Sumitomo Chemical  
ULVAC  
Ningbo Jiangfeng  
Luvata  
GRIKIN Advanced Material  
Luoyang Sifon Electronic Materials  
FURAYA Metals  
Advantec  
Fujian Acetron New Materials Co., Ltd  
Umicore Thin Film Products  
Angstrom Sciences  
Changzhou Sujing Electronic Material

### **Sputtering Target for Semiconductor Segment by Type**

Metal Target  
Alloy Target  
Ceramic Compound Target

### **Sputtering Target for Semiconductor Segment by Application**

Consumer Electronics  
Vehicle Electronics  
Communication Electronics  
Others

### **Sputtering Target for Semiconductor Segment by Region**

North America  
United States  
Canada  
Mexico  
Europe  
Germany  
France  
U.K.  
Italy  
Russia  
Spain  
Netherlands  
Switzerland  
Sweden  
Poland  
Asia-Pacific  
China  
Japan  
South Korea  
India

Australia  
Taiwan  
Southeast Asia  
South America  
Brazil  
Argentina  
Chile  
Middle East & Africa  
Egypt  
South Africa  
Israel  
Türkiye  
GCC Countries

## **Key Drivers & Barriers**

High-impact rendering factors and drivers have been studied in this report to aid the readers to understand the general development. Moreover, the report includes restraints and challenges that may act as stumbling blocks on the way of the players. This will assist the users to be attentive and make informed decisions related to business. Specialists have also laid their focus on the upcoming business prospects.

## **Reasons to Buy This Report**

1. This report will help the readers to understand the competition within the industries and strategies for the competitive environment to enhance the potential profit. The report also focuses on the competitive landscape of the global Sputtering Target for Semiconductor market, and introduces in detail the market share, industry ranking, competitor ecosystem, market performance, new product development, operation situation, expansion, and acquisition. etc. of the main players, which helps the readers to identify the main competitors and deeply understand the competition pattern of the market.
2. This report will help stakeholders to understand the global industry status and trends of Sputtering Target for Semiconductor and provides them with information on key market drivers, restraints, challenges, and opportunities.
3. This report will help stakeholders to understand competitors better and gain more insights to strengthen their position in their businesses. The competitive landscape section includes the market share and rank (in volume and value), competitor ecosystem, new product development, expansion, and acquisition.
4. This report stays updated with novel technology integration, features, and the latest developments in the market
5. This report helps stakeholders to gain insights into which regions to target globally
6. This report helps stakeholders to gain insights into the end-user perception concerning the adoption of Sputtering Target for Semiconductor.
7. This report helps stakeholders to identify some of the key players in the market and understand their valuable contribution.

## **Chapter Outline**

### **Chapter 1:**

Research objectives, research methods, data sources, data cross-validation;

### **Chapter 2:**

Introduces the report scope of the report, executive summary of different market segments (by region, product type, application, etc), including the market size of each market segment, future development potential, and so on. It offers a high-level view of the current state of the market and its likely evolution in the short to mid-term, and long term.

**Chapter 3:**

Detailed analysis of Sputtering Target for Semiconductor manufacturers competitive landscape, price, production and value market share, latest development plan, merger, and acquisition information, etc.

**Chapter 4:**

Provides profiles of key players, introducing the basic situation of the main companies in the market in detail, including product production/output, value, price, gross margin, product introduction, recent development, etc.

**Chapter 5:**

Production/output, value of Sputtering Target for Semiconductor by region/country. It provides a quantitative analysis of the market size and development potential of each region in the next six years.

**Chapter 6:**

Consumption of Sputtering Target for Semiconductor in regional level and country level. It provides a quantitative analysis of the market size and development potential of each region and its main countries and introduces the market development, future development prospects, market space, and production of each country in the world.

**Chapter 7:**

Provides the analysis of various market segments by type, covering the market size and development potential of each market segment, to help readers find the blue ocean market in different market segments.

**Chapter 8:**

Provides the analysis of various market segments by application, covering the market size and development potential of each market segment, to help readers find the blue ocean market in different downstream markets.

**Chapter 9:**

Analysis of industrial chain, including the upstream and downstream of the industry.

**Chapter 10:**

Introduces the market dynamics, latest developments of the market, the driving factors and restrictive factors of the market, the challenges and risks faced by manufacturers in the industry, and the analysis of relevant policies in the industry.

**Chapter 11:**

The main points and conclusions of the report.

# Table of Contents

---

## 1 Preface

- 1.1 Scope of Report
- 1.2 Reasons for Doing This Study
- 1.3 Research Methodology
- 1.4 Research Process
- 1.5 Data Source
  - 1.5.1 Secondary Sources
  - 1.5.2 Primary Sources

---

## 2 Market Overview

- 2.1 Product Definition
- 2.2 Sputtering Target for Semiconductor by Type
  - 2.2.1 Market Value Comparison by Type (2021 VS 2025 VS 2032) & (US\$ Million)
  - 2.2.2 Metal Target
  - 2.2.3 Alloy Target
  - 2.2.4 Ceramic Compound Target
- 2.3 Sputtering Target for Semiconductor by Application
  - 2.3.1 Market Value Comparison by Application (2021 VS 2025 VS 2032) & (US\$ Million)
  - 2.3.2 Consumer Electronics
  - 2.3.3 Vehicle Electronics
  - 2.3.4 Communication Electronics
  - 2.3.5 Others
- 2.4 Global Market Growth Prospects
  - 2.4.1 Global Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2021-2032)
  - 2.4.2 Global Sputtering Target for Semiconductor Production Capacity Estimates and Forecasts (2021-2032)
  - 2.4.3 Global Sputtering Target for Semiconductor Production Estimates and Forecasts (2021-2032)
  - 2.4.4 Global Sputtering Target for Semiconductor Market Average Price (2021-2032)

---

## 3 Market Competitive Landscape by Manufacturers

- 3.1 Global Sputtering Target for Semiconductor Production by Manufacturers (2021-2026)
- 3.2 Global Sputtering Target for Semiconductor Production Value by Manufacturers (2021-2026)
- 3.3 Global Sputtering Target for Semiconductor Average Price by Manufacturers (2021-2026)
- 3.4 Global Sputtering Target for Semiconductor Industry Manufacturers Ranking, 2024 VS 2025 VS 2026
- 3.5 Global Sputtering Target for Semiconductor Key Manufacturers, Manufacturing Sites & Headquarters
- 3.6 Global Sputtering Target for Semiconductor Manufacturers, Product Type & Application
- 3.7 Global Sputtering Target for Semiconductor Manufacturers Established Date
- 3.8 Global Sputtering Target for Semiconductor Market CR5 and HHI
- 3.9 Global Manufacturers Mergers & Acquisition

---

## 4 Manufacturers Profiled

- 4.1 Materion (Heraeus)
  - 4.1.1 Materion (Heraeus) Sputtering Target for Semiconductor Company Information
  - 4.1.2 Materion (Heraeus) Sputtering Target for Semiconductor Business Overview
  - 4.1.3 Materion (Heraeus) Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)
  - 4.1.4 Materion (Heraeus) Product Portfolio
  - 4.1.5 Materion (Heraeus) Recent Developments

## 4.2 JX Nippon Mining & Metals Corporation

4.2.1 JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Company Information

4.2.2 JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Business Overview

4.2.3 JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.2.4 JX Nippon Mining & Metals Corporation Product Portfolio

4.2.5 JX Nippon Mining & Metals Corporation Recent Developments

## 4.3 Praxair

4.3.1 Praxair Sputtering Target for Semiconductor Company Information

4.3.2 Praxair Sputtering Target for Semiconductor Business Overview

4.3.3 Praxair Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.3.4 Praxair Product Portfolio

4.3.5 Praxair Recent Developments

## 4.4 Plansee SE

4.4.1 Plansee SE Sputtering Target for Semiconductor Company Information

4.4.2 Plansee SE Sputtering Target for Semiconductor Business Overview

4.4.3 Plansee SE Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.4.4 Plansee SE Product Portfolio

4.4.5 Plansee SE Recent Developments

## 4.5 Hitachi Metals

4.5.1 Hitachi Metals Sputtering Target for Semiconductor Company Information

4.5.2 Hitachi Metals Sputtering Target for Semiconductor Business Overview

4.5.3 Hitachi Metals Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.5.4 Hitachi Metals Product Portfolio

4.5.5 Hitachi Metals Recent Developments

## 4.6 Honeywell

4.6.1 Honeywell Sputtering Target for Semiconductor Company Information

4.6.2 Honeywell Sputtering Target for Semiconductor Business Overview

4.6.3 Honeywell Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.6.4 Honeywell Product Portfolio

4.6.5 Honeywell Recent Developments

## 4.7 TOSOH

4.7.1 TOSOH Sputtering Target for Semiconductor Company Information

4.7.2 TOSOH Sputtering Target for Semiconductor Business Overview

4.7.3 TOSOH Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.7.4 TOSOH Product Portfolio

4.7.5 TOSOH Recent Developments

## 4.8 Sumitomo Chemical

4.8.1 Sumitomo Chemical Sputtering Target for Semiconductor Company Information

4.8.2 Sumitomo Chemical Sputtering Target for Semiconductor Business Overview

4.8.3 Sumitomo Chemical Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.8.4 Sumitomo Chemical Product Portfolio

4.8.5 Sumitomo Chemical Recent Developments

## 4.9 ULVAC

4.9.1 ULVAC Sputtering Target for Semiconductor Company Information

4.9.2 ULVAC Sputtering Target for Semiconductor Business Overview

4.9.3 ULVAC Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.9.4 ULVAC Product Portfolio

#### 4.9.5 ULVAC Recent Developments

#### 4.10 Ningbo Jiangfeng

4.10.1 Ningbo Jiangfeng Sputtering Target for Semiconductor Company Information

4.10.2 Ningbo Jiangfeng Sputtering Target for Semiconductor Business Overview

4.10.3 Ningbo Jiangfeng Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.10.4 Ningbo Jiangfeng Product Portfolio

4.10.5 Ningbo Jiangfeng Recent Developments

#### 4.11 Luvata

4.11.1 Luvata Sputtering Target for Semiconductor Company Information

4.11.2 Luvata Sputtering Target for Semiconductor Business Overview

4.11.3 Luvata Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.11.4 Luvata Product Portfolio

4.11.5 Luvata Recent Developments

#### 4.12 GRIKIN Advanced Material

4.12.1 GRIKIN Advanced Material Sputtering Target for Semiconductor Company Information

4.12.2 GRIKIN Advanced Material Sputtering Target for Semiconductor Business Overview

4.12.3 GRIKIN Advanced Material Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.12.4 GRIKIN Advanced Material Product Portfolio

4.12.5 GRIKIN Advanced Material Recent Developments

#### 4.13 Luoyang Sifon Electronic Materials

4.13.1 Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Company Information

4.13.2 Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Business Overview

4.13.3 Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.13.4 Luoyang Sifon Electronic Materials Product Portfolio

4.13.5 Luoyang Sifon Electronic Materials Recent Developments

#### 4.14 FURAYA Metals

4.14.1 FURAYA Metals Sputtering Target for Semiconductor Company Information

4.14.2 FURAYA Metals Sputtering Target for Semiconductor Business Overview

4.14.3 FURAYA Metals Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.14.4 FURAYA Metals Product Portfolio

4.14.5 FURAYA Metals Recent Developments

#### 4.15 Advantec

4.15.1 Advantec Sputtering Target for Semiconductor Company Information

4.15.2 Advantec Sputtering Target for Semiconductor Business Overview

4.15.3 Advantec Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.15.4 Advantec Product Portfolio

4.15.5 Advantec Recent Developments

#### 4.16 Fujian Acetron New Materials Co., Ltd

4.16.1 Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Company Information

4.16.2 Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Business Overview

4.16.3 Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.16.4 Fujian Acetron New Materials Co., Ltd Product Portfolio

4.16.5 Fujian Acetron New Materials Co., Ltd Recent Developments

#### 4.17 Umicore Thin Film Products

4.17.1 Umicore Thin Film Products Sputtering Target for Semiconductor Company Information

4.17.2 Umicore Thin Film Products Sputtering Target for Semiconductor Business Overview

4.17.3 Umicore Thin Film Products Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.17.4 Umicore Thin Film Products Product Portfolio

4.17.5 Umicore Thin Film Products Recent Developments

4.18 Angstrom Sciences

4.18.1 Angstrom Sciences Sputtering Target for Semiconductor Company Information

4.18.2 Angstrom Sciences Sputtering Target for Semiconductor Business Overview

4.18.3 Angstrom Sciences Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.18.4 Angstrom Sciences Product Portfolio

4.18.5 Angstrom Sciences Recent Developments

4.19 Changzhou Sujing Electronic Material

4.19.1 Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Company Information

4.19.2 Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Business Overview

4.19.3 Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Production, Value and Gross Margin (2021-2026)

4.19.4 Changzhou Sujing Electronic Material Product Portfolio

4.19.5 Changzhou Sujing Electronic Material Recent Developments

---

## 5 Global Sputtering Target for Semiconductor Production by Region

5.1 Global Sputtering Target for Semiconductor Production Estimates and Forecasts by Region: 2021 VS 2025 VS 2032

5.2 Global Sputtering Target for Semiconductor Production by Region: 2021-2032

5.2.1 Global Sputtering Target for Semiconductor Production by Region: 2021-2026

5.2.2 Global Sputtering Target for Semiconductor Production Forecast by Region (2027-2032)

5.3 Global Sputtering Target for Semiconductor Production Value Estimates and Forecasts by Region: 2021 VS 2025 VS 2032

5.4 Global Sputtering Target for Semiconductor Production Value by Region: 2021-2032

5.4.1 Global Sputtering Target for Semiconductor Production Value by Region: 2021-2026

5.4.2 Global Sputtering Target for Semiconductor Production Value Forecast by Region (2027-2032)

5.5 Global Sputtering Target for Semiconductor Market Price Analysis by Region (2021-2026)

5.6 Global Sputtering Target for Semiconductor Production and Value, YOY Growth

5.6.1 North America Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2021-2032)

5.6.2 Europe Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2021-2032)

5.6.3 China Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2021-2032)

5.6.4 Japan Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2021-2032)

5.6.5 South Korea Sputtering Target for Semiconductor Production Value Estimates and Forecasts (2021-2032)

---

## 6 Global Sputtering Target for Semiconductor Consumption by Region

6.1 Global Sputtering Target for Semiconductor Consumption Estimates and Forecasts by Region: 2021 VS 2025 VS 2032

6.2 Global Sputtering Target for Semiconductor Consumption by Region (2021-2032)

6.2.1 Global Sputtering Target for Semiconductor Consumption by Region: 2021-2026

6.2.2 Global Sputtering Target for Semiconductor Forecasted Consumption by Region (2027-2032)

6.3 North America

6.3.1 North America Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032

6.3.2 North America Sputtering Target for Semiconductor Consumption by Country (2021-2032)

6.3.3 United States

6.3.4 Canada

6.3.5 Mexico

6.4 Europe

6.4.1 Europe Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032

6.4.2 Europe Sputtering Target for Semiconductor Consumption by Country (2021-2032)

6.4.3 Germany

6.4.4 France

6.4.5 U.K.

6.4.6 Italy

6.4.7 Russia

6.4.8 Spain

6.4.9 Netherlands

6.4.10 Switzerland

6.4.11 Sweden

6.4.12 Poland

6.5 Asia Pacific

6.5.1 Asia Pacific Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032

6.5.2 Asia Pacific Sputtering Target for Semiconductor Consumption by Country (2021-2032)

6.5.3 China

6.5.4 Japan

6.5.5 South Korea

6.5.6 India

6.5.7 Australia

6.5.8 Taiwan

6.5.9 Southeast Asia

6.6 South America, Middle East & Africa

6.6.1 South America, Middle East & Africa Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032

6.6.2 South America, Middle East & Africa Sputtering Target for Semiconductor Consumption by Country (2021-2032)

6.6.3 Brazil

6.6.4 Argentina

6.6.5 Chile

6.6.6 Turkey

6.6.7 GCC Countries

---

## 7 Segment by Type

7.1 Global Sputtering Target for Semiconductor Production by Type (2021-2032)

7.1.1 Global Sputtering Target for Semiconductor Production by Type (2021-2032) & (Tons)

7.1.2 Global Sputtering Target for Semiconductor Production Market Share by Type (2021-2032)

7.2 Global Sputtering Target for Semiconductor Production Value by Type (2021-2032)

7.2.1 Global Sputtering Target for Semiconductor Production Value by Type (2021-2032) & (US\$ Million)

7.2.2 Global Sputtering Target for Semiconductor Production Value Market Share by Type (2021-2032)

7.3 Global Sputtering Target for Semiconductor Price by Type (2021-2032)

---

## 8 Segment by Application

8.1 Global Sputtering Target for Semiconductor Production by Application (2021-2032)

8.1.1 Global Sputtering Target for Semiconductor Production by Application (2021-2032) & (Tons)

8.1.2 Global Sputtering Target for Semiconductor Production Market Share by Application (2021-2032)

8.2 Global Sputtering Target for Semiconductor Production Value by Application (2021-2032)

8.2.1 Global Sputtering Target for Semiconductor Production Value by Application (2021-2032) & (US\$ Million)

8.2.2 Global Sputtering Target for Semiconductor Production Value Market Share by Application (2021-2032)

8.3 Global Sputtering Target for Semiconductor Price by Application (2021-2032)

---

## 9 Value Chain and Sales Channels Analysis of the Market

9.1 Sputtering Target for Semiconductor Value Chain Analysis

9.1.1 Sputtering Target for Semiconductor Key Raw Materials

9.1.2 Raw Materials Key Suppliers

9.1.3 Sputtering Target for Semiconductor Production Mode & Process

9.2 Sputtering Target for Semiconductor Sales Channels Analysis

9.2.1 Direct Comparison with Distribution Share

9.2.2 Sputtering Target for Semiconductor Distributors

9.2.3 Sputtering Target for Semiconductor Customers

---

## **10 Global Sputtering Target for Semiconductor Analyzing Market Dynamics**

10.1 Sputtering Target for Semiconductor Industry Trends

10.2 Sputtering Target for Semiconductor Industry Drivers

10.3 Sputtering Target for Semiconductor Industry Opportunities and Challenges

10.4 Sputtering Target for Semiconductor Industry Restraints

---

## **11 Report Conclusion**

---

## **12 Disclaimer**

# List of Tables and Figures

---

## List of Tables:

- Table 1: Secondary Sources
- Table 2: Primary Sources
- Table 3: Market Value Comparison by Type (2021 VS 2025 VS 2032) & (US\$ Million)
- Table 4: Market Value Comparison by Application (2021 VS 2025 VS 2032) & (US\$ Million)
- Table 5: Global Sputtering Target for Semiconductor Production by Manufacturers (Tons) & (2021-2026)
- Table 6: Global Sputtering Target for Semiconductor Production Market Share by Manufacturers
- Table 7: Global Sputtering Target for Semiconductor Production Value by Manufacturers (US\$ Million) & (2021-2026)
- Table 8: Global Sputtering Target for Semiconductor Production Value Market Share by Manufacturers (2021-2026)
- Table 9: Global Sputtering Target for Semiconductor Average Price (US\$/Kg) of Manufacturers (2021-2026)
- Table 10: Global Sputtering Target for Semiconductor Industry Manufacturers Ranking, 2024 VS 2025 VS 2026
- Table 11: Global Sputtering Target for Semiconductor Key Manufacturers, Manufacturing Sites & Headquarters
- Table 12: Global Sputtering Target for Semiconductor Manufacturers, Product Type & Application
- Table 13: Global Sputtering Target for Semiconductor Manufacturers Established Date
- Table 14: Global Manufacturers Market Concentration Ratio (CR5 and HHI)
- Table 15: Global Sputtering Target for Semiconductor by Manufacturers Type (Tier 1, Tier 2, and Tier 3) & (based on the Production Value of 2025)
- Table 16: Manufacturers Mergers & Acquisitions, Expansion Plans
- Table 17: Materion (Heraeus) Company Information
- Table 18: Materion (Heraeus) Business Overview
- Table 19: Materion (Heraeus) Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 20: Materion (Heraeus) Sputtering Target for Semiconductor Product Portfolio
- Table 21: Materion (Heraeus) Recent Development
- Table 22: JX Nippon Mining & Metals Corporation Company Information
- Table 23: JX Nippon Mining & Metals Corporation Business Overview
- Table 24: JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 25: JX Nippon Mining & Metals Corporation Sputtering Target for Semiconductor Product Portfolio
- Table 26: JX Nippon Mining & Metals Corporation Recent Development
- Table 27: Praxair Company Information
- Table 28: Praxair Business Overview
- Table 29: Praxair Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 30: Praxair Sputtering Target for Semiconductor Product Portfolio
- Table 31: Praxair Recent Development
- Table 32: Plansee SE Company Information
- Table 33: Plansee SE Business Overview
- Table 34: Plansee SE Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 35: Plansee SE Sputtering Target for Semiconductor Product Portfolio
- Table 36: Plansee SE Recent Development
- Table 37: Hitachi Metals Company Information
- Table 38: Hitachi Metals Business Overview
- Table 39: Hitachi Metals Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 40: Hitachi Metals Sputtering Target for Semiconductor Product Portfolio
- Table 41: Hitachi Metals Recent Development
- Table 42: Honeywell Company Information
- Table 43: Honeywell Business Overview
- Table 44: Honeywell Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 45: Honeywell Sputtering Target for Semiconductor Product Portfolio
- Table 46: Honeywell Recent Development
- Table 47: TOSOH Company Information
- Table 48: TOSOH Business Overview

- Table 49: TOSOH Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 50: TOSOH Sputtering Target for Semiconductor Product Portfolio
- Table 51: TOSOH Recent Development
- Table 52: Sumitomo Chemical Company Information
- Table 53: Sumitomo Chemical Business Overview
- Table 54: Sumitomo Chemical Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 55: Sumitomo Chemical Sputtering Target for Semiconductor Product Portfolio
- Table 56: Sumitomo Chemical Recent Development
- Table 57: ULVAC Company Information
- Table 58: ULVAC Business Overview
- Table 59: ULVAC Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 60: ULVAC Sputtering Target for Semiconductor Product Portfolio
- Table 61: ULVAC Recent Development
- Table 62: Ningbo Jiangfeng Company Information
- Table 63: Ningbo Jiangfeng Business Overview
- Table 64: Ningbo Jiangfeng Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 65: Ningbo Jiangfeng Sputtering Target for Semiconductor Product Portfolio
- Table 66: Ningbo Jiangfeng Recent Development
- Table 67: Luvata Company Information
- Table 68: Luvata Business Overview
- Table 69: Luvata Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 70: Luvata Sputtering Target for Semiconductor Product Portfolio
- Table 71: Luvata Recent Development
- Table 72: GRIKIN Advanced Material Company Information
- Table 73: GRIKIN Advanced Material Business Overview
- Table 74: GRIKIN Advanced Material Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 75: GRIKIN Advanced Material Sputtering Target for Semiconductor Product Portfolio
- Table 76: GRIKIN Advanced Material Recent Development
- Table 77: Luoyang Sifon Electronic Materials Company Information
- Table 78: Luoyang Sifon Electronic Materials Business Overview
- Table 79: Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 80: Luoyang Sifon Electronic Materials Sputtering Target for Semiconductor Product Portfolio
- Table 81: Luoyang Sifon Electronic Materials Recent Development
- Table 82: FURAYA Metals Company Information
- Table 83: FURAYA Metals Business Overview
- Table 84: FURAYA Metals Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 85: FURAYA Metals Sputtering Target for Semiconductor Product Portfolio
- Table 86: FURAYA Metals Recent Development
- Table 87: Advantec Company Information
- Table 88: Advantec Business Overview
- Table 89: Advantec Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 90: Advantec Sputtering Target for Semiconductor Product Portfolio
- Table 91: Advantec Recent Development
- Table 92: Fujian Acetron New Materials Co., Ltd Company Information
- Table 93: Fujian Acetron New Materials Co., Ltd Business Overview
- Table 94: Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 95: Fujian Acetron New Materials Co., Ltd Sputtering Target for Semiconductor Product Portfolio
- Table 96: Fujian Acetron New Materials Co., Ltd Recent Development
- Table 97: Umicore Thin Film Products Company Information
- Table 98: Umicore Thin Film Products Business Overview
- Table 99: Umicore Thin Film Products Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 100: Umicore Thin Film Products Sputtering Target for Semiconductor Product Portfolio
- Table 101: Umicore Thin Film Products Recent Development
- Table 102: Angstrom Sciences Company Information

- Table 103: Angstrom Sciences Business Overview
- Table 104: Angstrom Sciences Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 105: Angstrom Sciences Sputtering Target for Semiconductor Product Portfolio
- Table 106: Angstrom Sciences Recent Development
- Table 107: Changzhou Sujing Electronic Material Company Information
- Table 108: Changzhou Sujing Electronic Material Business Overview
- Table 109: Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Production (Tons), Value (US\$ Million), Price (US\$/Kg) and Gross Margin (2021-2026)
- Table 110: Changzhou Sujing Electronic Material Sputtering Target for Semiconductor Product Portfolio
- Table 111: Changzhou Sujing Electronic Material Recent Development
- Table 112: Global Sputtering Target for Semiconductor Production Comparison by Region: 2021 VS 2025 VS 2032 (Tons)
- Table 113: Global Sputtering Target for Semiconductor Production by Region (2021-2026) & (Tons)
- Table 114: Global Sputtering Target for Semiconductor Production Market Share by Region (2021-2026)
- Table 115: Global Sputtering Target for Semiconductor Production Forecast by Region (2027-2032) & (Tons)
- Table 116: Global Sputtering Target for Semiconductor Production Market Share Forecast by Region (2027-2032)
- Table 117: Global Sputtering Target for Semiconductor Production Value Comparison by Region: 2021 VS 2025 VS 2032 (US\$ Million)
- Table 118: Global Sputtering Target for Semiconductor Production Value by Region (2021-2026) & (US\$ Million)
- Table 119: Global Sputtering Target for Semiconductor Production Value Market Share by Region (2021-2026)
- Table 120: Global Sputtering Target for Semiconductor Production Value Forecast by Region (2027-2032) & (US\$ Million)
- Table 121: Global Sputtering Target for Semiconductor Market Average Price (US\$/Kg) by Region (2021-2026)
- Table 122: Global Sputtering Target for Semiconductor Market Average Price (US\$/Kg) by Region (2027-2032)
- Table 123: Global Sputtering Target for Semiconductor Consumption Comparison by Region: 2021 VS 2025 VS 2032 (Tons)
- Table 124: Global Sputtering Target for Semiconductor Consumption by Region (2021-2026) & (Tons)
- Table 125: Global Sputtering Target for Semiconductor Consumption Market Share by Region (2021-2026)
- Table 126: Global Sputtering Target for Semiconductor Forecasted Consumption by Region (2027-2032) & (Tons)
- Table 127: Global Sputtering Target for Semiconductor Forecasted Consumption Market Share by Region (2027-2032)
- Table 128: North America Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032 (Tons)
- Table 129: North America Sputtering Target for Semiconductor Consumption by Country (2021-2026) & (Tons)
- Table 130: North America Sputtering Target for Semiconductor Consumption by Country (2027-2032) & (Tons)
- Table 131: Europe Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032 (Tons)
- Table 132: Europe Sputtering Target for Semiconductor Consumption by Country (2021-2026) & (Tons)
- Table 133: Europe Sputtering Target for Semiconductor Consumption by Country (2027-2032) & (Tons)
- Table 134: Asia Pacific Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032 (Tons)
- Table 135: Asia Pacific Sputtering Target for Semiconductor Consumption by Country (2021-2026) & (Tons)
- Table 136: Asia Pacific Sputtering Target for Semiconductor Consumption by Country (2027-2032) & (Tons)
- Table 137: South America, Middle East & Africa Sputtering Target for Semiconductor Consumption Growth Rate by Country: 2021 VS 2025 VS 2032 (Tons)
- Table 138: South America, Middle East & Africa Sputtering Target for Semiconductor Consumption by Country (2021-2026) & (Tons)
- Table 139: South America, Middle East & Africa Sputtering Target for Semiconductor Consumption by Country (2027-2032) & (Tons)
- Table 140: Global Sputtering Target for Semiconductor Production by Type (2021-2026) & (Tons)
- Table 141: Global Sputtering Target for Semiconductor Production by Type (2027-2032) & (Tons)
- Table 142: Global Sputtering Target for Semiconductor Production Market Share by Type (2021-2026)
- Table 143: Global Sputtering Target for Semiconductor Production Market Share by Type (2027-2032)
- Table 144: Global Sputtering Target for Semiconductor Production Value by Type (2021-2026) & (US\$ Million)
- Table 145: Global Sputtering Target for Semiconductor Production Value by Type (2027-2032) & (US\$ Million)
- Table 146: Global Sputtering Target for Semiconductor Production Value Market Share by Type (2021-2026)
- Table 147: Global Sputtering Target for Semiconductor Production Value Market Share by Type (2027-2032)
- Table 148: Global Sputtering Target for Semiconductor Price by Type (2021-2026) & (US\$/Kg)
- Table 149: Global Sputtering Target for Semiconductor Price by Type (2027-2032) & (US\$/Kg)
- Table 150: Global Sputtering Target for Semiconductor Production by Application (2021-2026) & (Tons)
- Table 151: Global Sputtering Target for Semiconductor Production by Application (2027-2032) & (Tons)
- Table 152: Global Sputtering Target for Semiconductor Production Market Share by Application (2021-2026)
- Table 153: Global Sputtering Target for Semiconductor Production Market Share by Application (2027-2032)
- Table 154: Global Sputtering Target for Semiconductor Production Value by Application (2021-2026) & (US\$ Million)
- Table 155: Global Sputtering Target for Semiconductor Production Value by Application (2027-2032) & (US\$ Million)
- Table 156: Global Sputtering Target for Semiconductor Production Value Market Share by Application (2021-2026)
- Table 157: Global Sputtering Target for Semiconductor Production Value Market Share by Application (2027-2032)
- Table 158: Global Sputtering Target for Semiconductor Price by Application (2021-2026) & (US\$/Kg)
- Table 159: Global Sputtering Target for Semiconductor Price by Application (2027-2032) & (US\$/Kg)

- Table 160: Key Raw Materials
- Table 161: Raw Materials Key Suppliers
- Table 162: Sputtering Target for Semiconductor Distributors List
- Table 163: Sputtering Target for Semiconductor Customers List
- Table 164: Sputtering Target for Semiconductor Industry Trends
- Table 165: Sputtering Target for Semiconductor Industry Drivers
- Table 166: Sputtering Target for Semiconductor Industry Restraints
- Table 167: Authors List of This Report

## List of Figures:

- Figure 1: Research Methodology
- Figure 2: Research Process
- Figure 3: Key Executives Interviewed
- Figure 4: Sputtering Target for Semiconductor Product Image
- Figure 5: Market Value Comparison by Type (2021 VS 2025 VS 2032) & (US\$ Million)
- Figure 6: Metal Target Product Image
- Figure 7: Alloy Target Product Image
- Figure 8: Ceramic Compound Target Product Image
- Figure 9: Consumer Electronics Product Image
- Figure 10: Vehicle Electronics Product Image
- Figure 11: Communication Electronics Product Image
- Figure 12: Others Product Image
- Figure 13: Global Sputtering Target for Semiconductor Production Value (US\$ Million), 2021 VS 2025 VS 2032
- Figure 14: Global Sputtering Target for Semiconductor Production Value (2021-2032) & (US\$ Million)
- Figure 15: Global Sputtering Target for Semiconductor Production Capacity (2021-2032) & (Tons)
- Figure 16: Global Sputtering Target for Semiconductor Production (2021-2032) & (Tons)
- Figure 17: Global Sputtering Target for Semiconductor Average Price (US\$/Kg) & (2021-2032)
- Figure 18: Global Sputtering Target for Semiconductor Key Manufacturers, Manufacturing Sites & Headquarters
- Figure 19: Global Top 5 and 10 Sputtering Target for Semiconductor Players Market Share by Production Value in 2025
- Figure 20: Manufacturers Type (Tier 1, Tier 2, and Tier 3): 2021 VS 2025
- Figure 21: Global Sputtering Target for Semiconductor Production Comparison by Region: 2021 VS 2025 VS 2032 (Tons)
- Figure 22: Global Sputtering Target for Semiconductor Production Market Share by Region: 2021 VS 2025 VS 2032
- Figure 23: Global Sputtering Target for Semiconductor Production Value Comparison by Region: 2021 VS 2025 VS 2032 (US\$ Million)
- Figure 24: Global Sputtering Target for Semiconductor Production Value Market Share by Region: 2021 VS 2025 VS 2032
- Figure 25: North America Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2021-2032)
- Figure 26: Europe Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2021-2032)
- Figure 27: China Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2021-2032)
- Figure 28: Japan Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2021-2032)
- Figure 29: South Korea Sputtering Target for Semiconductor Production Value (US\$ Million) Growth Rate (2021-2032)
- Figure 30: Global Sputtering Target for Semiconductor Consumption Comparison by Region: 2021 VS 2025 VS 2032 (Tons)
- Figure 31: Global Sputtering Target for Semiconductor Consumption Market Share by Region: 2021 VS 2025 VS 2032
- Figure 32: North America Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 33: North America Sputtering Target for Semiconductor Consumption Market Share by Country (2021-2032)
- Figure 34: United States Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 35: United States Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 36: Canada Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 37: Mexico Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 38: Europe Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 39: Europe Sputtering Target for Semiconductor Consumption Market Share by Country (2021-2032)
- Figure 40: Germany Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 41: France Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 42: U.K. Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 43: Italy Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 44: Russia Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 45: Spain Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 46: Netherlands Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 47: Switzerland Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 48: Sweden Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 49: Poland Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 50: Asia Pacific Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 51: Asia Pacific Sputtering Target for Semiconductor Consumption Market Share by Country (2021-2032)
- Figure 52: China Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)

- Figure 53: Japan Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 54: South Korea Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 55: India Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 56: Australia Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 57: Taiwan Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 58: Southeast Asia Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 59: South America, Middle East & Africa Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 60: South America, Middle East & Africa Sputtering Target for Semiconductor Consumption Market Share by Country (2021-2032)
- Figure 61: Brazil Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 62: Argentina Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 63: Chile Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 64: Turkey Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 65: GCC Countries Sputtering Target for Semiconductor Consumption and Growth Rate (2021-2032) & (Tons)
- Figure 66: Global Sputtering Target for Semiconductor Production Market Share by Type (2021-2032)
- Figure 67: Global Sputtering Target for Semiconductor Production Value Market Share by Type (2021-2032)
- Figure 68: Global Sputtering Target for Semiconductor Price (US\$/Kg) by Type (2021-2032)
- Figure 69: Global Sputtering Target for Semiconductor Production Market Share by Application (2021-2032)
- Figure 70: Global Sputtering Target for Semiconductor Production Value Market Share by Application (2021-2032)
- Figure 71: Global Sputtering Target for Semiconductor Price (US\$/Kg) by Application (2021-2032)
- Figure 72: Sputtering Target for Semiconductor Value Chain
- Figure 73: Sputtering Target for Semiconductor Production Mode & Process
- Figure 74: Direct Comparison with Distribution Share
- Figure 75: Distributors Profiles
- Figure 76: Sputtering Target for Semiconductor Industry Opportunities and Challenges